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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/790,199	03/02/2004	Yoshihisa Tashiro	402991	1023
23548	7590 12/15/2005		EXAMINER	
LEYDIG VOIT & MAYER, LTD 700 THIRTEENTH ST. NW			REAMES, MATTHEW L	
SUITE 300	AVIII 51. IVW		ART UNIT	PAPER NUMBER
WASHINGTO	ON, DC 20005-3960		2891	

DATE MAILED: 12/15/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)	
Office Action Summary		10/790,199	TASHIRO ET AL.	v
		Examiner	Art Unit	
		Matthew L. Reames	2891	
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with the	correspondence address	
WHIC - Exter after - If NO - Failur Any (ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DAY INSIGNS OF THE MAILING DAY INSIGNS OF THE MAY IN THE MAILING DAY IN THE	ATE OF THIS COMMUNICATIO 36(a). In no event, however, may a reply be ti will apply and will expire SIX (6) MONTHS fror cause the application to become ABANDON	N. imely filed in the mailing date of this communication ED (35 U.S.C. § 133).	
Status				ĺ
2a)□	Responsive to communication(s) filed on <u>03/02</u> This action is FINAL . 2b) This Since this application is in condition for alloward closed in accordance with the practice under Expression 1.	action is non-final. nce except for formal matters, p	rosecution as to the merits is 153 O.G. 213.	
Dispositi	ion of Claims			
5)□ 6)⊠ 7)□	Claim(s) 7-9 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw Claim(s) is/are allowed. Claim(s) 7-9 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or claim(s) are subject to restriction.			
Applicat	ion Papers			
10)	The specification is objected to by the Examine The drawing(s) filed on is/are: a) acc Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the E	cepted or b) objected to by the drawing(s) be held in abeyance. Setion is required if the drawing(s) is contact the drawing(s) is contact to the drawing(s) is contact to the drawing(s) is contact to the drawing(s).	see 37 CFR 1.85(a). objected to. See 37 CFR 1.121(d	d).
Priority	under 35 U.S.C. § 119			
12)⊠ a)	Acknowledgment is made of a claim for foreign	nts have been received. Its have been received in Applicate ority documents have been receing (PCT Rule 17.2(a)).	ation No ived in this National Stage	
2) Not	int(s) ice of References Cited (PTO-892) ice of Draftsperson's Patent Drawing Review (PTO-948) ormation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 over No(s)/Mail Date 03/02/2004.	4) Interview Summa Paper No(s)/Mai 5) Notice of Informa 6) Other:		

U.S. Patent and Trademark Office PTOL-326 (Ray. 7-05) Application/Control Number: 10/790,199

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DETAILED ACTION

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Regarding claim 8-9, the phrase "if" renders the claim indefinite because it is unclear whether the limitation(s) following the phrase are part of the claimed invention. See MPEP § 2173.05(d). The term "if the semiconductor laser" makes it unclear what are the limitations of the claims:

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to

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consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over Nagai (admitted prior art US-5797).

As to claim 7, Nagai teaches a semiconductor laser device fabricating method including: forming a first cladding layer of a first conductivity type (fig. 3 item2), an active layer having a quantum well structure (fig. 3 item 3), and a first second cladding layer of a second conductivity type successively on a semiconductor substrate of the first conductivity type (fig. 3 item 4); forming on the first second cladding layer a mask pattern for impurity implantation having an opening in a region where a resonator facet of a semiconductor laser device is to be formed (column 5 lines 55-60); disordering the active layer near the resonator facet by introducing impurities using the mask pattern as a mask (see e.g. column 5 lines 55-60); forming a second a second cladding layer of the second conductivity type on said first second cladding layer after removing the mask pattern (fig. 3 item 10); forming on said second second cladding layer a stripeshaped mask pattern opposed to the disordered active layer across the first and, the second second cladding lavers (column 5 lines 60-65), the stripe-shaped mask pattern extending in a resonator lengthwise direction; and forming an optical waveguide including the second second cladding layer with the stripeshaped mask pattern used as a mask(column 5 lines 60-65 and column 10 lines 15-20).

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Nagai does not teach explicitly teach applying pump light to the disordered region to generate photoluminescence.

However it would have been obvious to one of ordinary skill in the art to optically pump the active region to obtain a photoluminscence spectra (PL), thereby allowing one to make a prediction about the peak wavelength, (see for example Cho US 5,494,850 column3 lines 34-37).

Allowable Subject Matter

Claim 8 and 9 would be allowable if rewritten to overcome the rejection(s) under 35 U.S.C. 112, 2nd paragraph, set forth in this Office action and to include all of the limitations of the base claim and any intervening claims.

The following is a statement of reasons for the indication of allowable subject matter: O'brien (US 6,396,864) discloses that COD is related to thermal event. Mori (US 5,728,623) teaches measuring photoluminescence shift corresponds to the thermal stress of the object. Yoshida (US 5,617,957) teaches injection current (pump current) is related to the COD or the power of the COD. Further, the photons being ejected represent a power output since the energy of a given photon is given by Plank's constant times the frequency of the given photon. But the prior art does not teach λ bl \geq 20 nm or the equivalent power output. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Matthew L. Reames whose telephone number is (571)272-2408. The examiner can normally be reached on M-Th 6:30-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Bradley W. Baumeister can be reached on (571)272-1722. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

B. WILLIAM BAUMEISTED

SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800

MLR